

RELATION BETWEEN ELECTROCHEMICAL REACTIVITY AND STRUCTURE OF GRAIN BOUNDARIES CORRELATED TO INTERGRANULAR SULFUR SEGREGATION IN ULTRA PURE NICKEL

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<u>Résumé</u> - Dans un nickel ultra pur dopé à 8 et 16 ppm de soufre, nous avons caractérisé la cinétique de ségrégation et l'état d'équilibre des joints de grains ségrégés en soufre grâce à un test de corrosion électrochimique. Le nickel de base et l'échantillon le plus ségrégé sont observés au microscope électronique à transmission afin d'établir un histogramme de la structure des joints de grains étudiés et de déterminer les paramètres cristallographiques des joints les plus chargés en soufre. Ces résultats sont corrélés avec la réactivité électrochimique et l'analyse quantitative en microscopie électronique à balayage à transmission.

<u>Abstract</u> - In a ultra pure nickel doped with 8 and 16 ppm of sulfur, we have determined the kineticsand equilibrium state of segregated sulfur at grain boundaries by electrochemical corrosion test. The undoped nickel and the highest segregated specimen are observed in transmission electron microscopy in order to correlate the structural histogram with electrochemical reactivity study and analytical scanning transmission electron microscope experiments.

Even at very low concentration (few ppm) the presence of sulfur in nickel and nickel alloys gives rise to intergranular segregation. This is known to alter significantly grain boundary properties, especially embrittlement and intergranular corrosion susceptibility /1,2/.

In the case of intergranular corrosion, the process is governed by the atomic interaction but the details will depend on the atomic structure of grain boundaries and segregation.

The segregation level is controlled by the nature and concentration of present elements and the structure of the grain boundaries. Theoretical studies have been developed in order to understand the nature of segregation sites /3,4/ and the effect of the atomic structure disturbance by electronic structure (Ni-S chemical bonding) /5/. Previous works have discussed the variation of the amount of segregation with grain boundary type /6,7,8/: segregation occurs preferentially to high energy boundaries which have more segregation sites and then reduces their energy more than low ones. The different energy reduction for random and special grain boundaries tends to equalize the energies.

The present paper shows experimental results of correlation between corrosion reactivity, grain boundary structure and the amount of segregated sulfur at grain boundaries in a very high purity nickel.

MATERIALS

The high purity nickel Ni-OS is a vacuum plasma melted nickel which contains 160 ppm Si in weight, 45 ppm Na and S, P, Pt, Fe, Cu, Cr, Ca, As, Al, less than 2 ppm. This metal is doped with 8 and 16 ppm S in order to have an alloy each side of the limit of solubility for sulfur in nickel at 10 ppm /9/. Specimens are named respectively Ni-8S and Ni-16S. The three metals are cold rolled at 80% (thickness 5 mm) and annealed in quartz tube with argon hydrogen atmosphere, firstly at $1050^{\circ}C - 4$ hours to develop and stabilize grain boundaries structure, secondly at segregation temperature $625^{\circ}C$ determined in a previous work /2/ for different times up to 12 days.

I - ELECTROCHEMICAL REACTIVITY OF GRAIN BOUNDARIES

EXPERIMENTALS

In an earlier work we have performed an electrochemical test whose sensibility is proportional to the level of segregation in grain boundaries /2,10/. This experiment is based on the attack of Fe-Ni-Cr alloys at transpassive electrochemical potential in sulfuric acid solution $H_2SO_4 - 2N - 25^{\circ}C$. Current and potential parameters are chosen and the quantity of electricity $(20C/cm^2)$ is rigorously controlled in order to dissolve a known quantity of metal. The intergranular attack develops a triangular groove at the emergence of grain boundaries on the surface. We measure the depth D, the width W and the dihedral angle α with a scanning electron microscope. We have a particular attention for the depth which is proportional to the amount of sulfur segregation and is measured for each grain boundary /2/ with respect to its individuality. The average value of twenty measures gives the global evaluation for each specimen.

RESULTS

Aspects of surface corrosion are given on the micrographs 1a and 1b respectively for Ni-OS, $1050^{\circ}C - 4$ hours, and Ni-16S, $1050^{\circ}C - 4$ hours + $625^{\circ}C - 2$ days. We observe the presence of low energy grain boundaries and coherent twins which are less attacked than high energy grain boundaries and incoherent twins. This classification has been demonstrated on stainless steel bicrystals /11/ and confirmed on Ni-OS bicrystals /12/. This is coherent with the fact that a grain boundary without impurity segregation is poorly attacked /13/.



Fig. 1a - Pure Ni, 1050°C - 4 hours.

Fig. 1b - Ni-16S, 1050°C - 4 hours + 625°C - 2 days.

The micrographs 2a and 2b allow to compare the features of the ultra pure nickel groove and these of Ni-16S respectively for an annealing of 1050° C - 4 hours + 625°C - 2 days corresponding to the maximum corrosion level.

Figure 3 gives the evolution of the dihedral angle α versus segregation heat treatment time at 625°C. This angle is inversely proportional to the segregated sulfur concentration. Up to two days of annealing the angle reaches a constant value : $\alpha = 55^{\circ}$ for Ni-8S and $\alpha = 45^{\circ}$ for Ni-16S. The first part of the curve corresponds to the kinetical evolution of the segregation and the second part to the stable equilibrium segregation. We remark that the angle is larger for Ni-8S which corresponds to the alloy below the solubility limit of sulfur in nickel at 625°C (10 ppm S) than for Ni-16S above this limit.

Figure 4 gives the depth of intergranular grooves versus heating time at 625°C. It is proportional to the segregated amount of sulfur. In this figure, depth increases for Ni-8S and Ni-16S and reaches two different constant levels after four days of temperature treatment but we observe a maximum in the case of Ni-16S for two days.



Fig. 2a - Pure Ni, 1050°C - 4 hours + 625°C - 2 days. Weak electrochemical groove



Fig. 2b - Ni-16S, 1050°C - 4 hours + 625°C - 2 days. Sharp and deep electrochemical groove



Fig. 3 - Evolution of the average angle of the intergranular groove versus the time of segregation treatment at 625°C.



Fig. 4 - Corrosion penetration at grain boundaries versus the time of segregation treatment at 625°C.

We note that for ultra pure nickel no evolution is revealed. This low value of penetration corresponds to non segregated grain boundaries (Fig. 4).

For the specimen Ni-8S, below the limit of solubility, a kinetical evolution of segregation occurs up to four days and then the segregation reaches a limit value for longer time of treatment up to twelve days. In the case of Ni-16S, above the solubility limit, the same evolution is observed but with a maximum of corrosion for two days of treatment; this last fact can be explained either by a morphological change of grain boundaries structure or by a precipitation between two and four days of annealing but, UP today, any experimental observation can confirm these hypothesis.

In this study we have observed that the ultra pure nickel is poorly attacked because we have numerous twins and low energy grain boundaries; only some high energy grain boundaries are attacked with no segregation but with disordered structure effect they represent 2% of all grain boundaries. For Ni-8S and Ni-16S, our results give 80 and 82% of grain boundaries well sensibilized by sulfur.

For each specimen and each heat treatment we study twenty grain boundary grooves to take into account the cristallographical structure of each interface. If we attribute the low values of penetration to low misorientation or coIncidence boundaries and the higher penetrations to high misorientations /10,11/ it appears on Fig. 5 that sulfur segregation during twelve days multiplies the corrosion penetration by two for low and by four for high misorientation boundaries. On the same figure one can see for the treatment of 1050°C - 4 hours on Ni-16S a spread of 5μ on the corrosion penetration depth of the nonsensitized Ni-16S while the spread is 20μ for the Ni-16S segregated at 625°C - 12 days. We can conclude that the segregation strongly enhances the difference of corrosion penetration must lower intergranular energy, then from our experiments we can conclude that corrosion is more sensitive to the chemical effect of sulfur atoms that to the possible energy reduction induced by segregation.



Fig. 5 - Corrosion penetration depth for sensitized and nonsensitized Ni-16S versus grain boundary misorientation.

Specimens with no segregation Ni-OS and with maximum segregation Ni-16S, $1050^{\circ}C - 4$ hours + $625^{\circ}C - 2$ days, are chosen for observation in the transmission electron microscope and analytical electron microscope.

II - RELATION BETWEEN INTERGRANULAR SULFUR SEGREGATION AND GRAIN BOUNDARY STRUCTU-RE BY TEM

The present TEM investigation has two strongly connected purposes : 1/ the first one is to study the statistical distribution of grain boundary types as a function of the segregation level in Ni-OS (specimen without segregation) and Ni-16S (specimen with maximum sulfur segregation). These samples have been previously selected by corrosion (cf. part I). Furthermore, crystallographical features (misorientation and grain boundary planes) of the boundaries with a maximum content of segregated sulfur are determined.

2/besides of its own interest,this part is a required preliminary work to the experiments on segregated sulfur detection by STEM (cf. part III) : for the first analysis, it is necessary to select grain boundaries which are known to contain a maximum sulfur amount.

EXPERIMENTALS

- Disks foils are extracted from the bulk specimens which have been studied by corrosion. Foils are thinned either by double jet technique for TEM studies or by ion-milling for STEM studies.

- Crystallographical analysis of grain boundary : once the misorientation is determined, relatively to the reference trihedral, the boundary is classified as "special" or "general" according to a geometrical criterion established in earlier works /14,15/. We consider as "special" all C.S.L. boundaries up to Σ = 19 and C.A.D. Finally, the boundary plane is indexed in both crystals.

- The study by TEM is always preceded by an optical microscope examination of the bulk specimen.

II - 1 - STATISTICAL DISTRIBUTION OF GRAIN BOUNDARY TYPES

The very large grain size (# 2 mm), did not allow to study more than 20 boundaries for each specimen.

GB types	Ni-OS	Ni-16S
GENERAL GB	20%	43%
SPECIAL GB	$30\% \Sigma = 3$ $50\% \Sigma > 3$	$48\% \Sigma = 3$ $9\% \Sigma > 3$
17% of Σ 3 are facetted		36% of Σ 3 are facetted

TABLE 1 : Influence of average sulfur segregation on the grain boundary types.

- These results show that the proportion of "special" boundaries (all Σ up to 19) is a lot higher (80%) in the pure Ni-OS, i.e. in the specimen without segregation, than in Ni-16S. In Ni-OS, the special boundaries are able to adopt coïncidence configurations of any low Σ . At the opposite, in Ni-16S, the special grain boundaries are nearly all Σ = 3 boundaries. This result has been confirmed by optical micrography of the whole specimens. Until now, no satisfactory interpretation can be done for this phenomenon.

- For the second purpose of this work, the important result of this part is that, in the specimen containing maximum average sulfur segregation, grain boundaries are mainly either general or Σ = 3 boundaries. Furthermore the facetting of Σ = 3 boundaries is more important in this Ni-16S sample.

II - 2 - CRYSTALLOGRAPHICAL PARAMETERS OF GRAIN BOUNDARIES WITH A MAXIMUM SULFUR SEGREGATION. INFLUENCE OF GRAIN BOUNDARY PLANE. MICROETCHING IN Ni-16S

The next step is to determine, for a given specimen, in which type of boundary the sulfur is preferentially segregated : during the electrolytical thinning of the foils, some grain boundaries or parts of boundary are selectively microetched. We have shown in a earlier work, that it is possible to establish a correlation between these microetchings and the presence of maximum sulfur segregation (out of precipitation) in the boundary. The microetching is very acute and does not hinder the TEM crystallographical analysis.

Table II summarizes the results in Ni-16S :

	GRAIN BOUNDARY TYPES AND PLANES	SEGREGATION LEVEL
	SPECIAL BOUNDARY	none or minimum segregation
	GENERAL BOUNDARY (Fig. 6)	maximum continuous segregation along the boundary
	<pre>FACETTED Σ = 3 : 1/ symmetrical facet (Fig. 7a) (compact place {111} or {211}) 2/ non symmetrical facet (Fig. 7b) (only one compact plane) 3/ symmetrical facet (Fig. 7a) (non compact GB plane {110} or {210})</pre>	no segregation punctual segregation continuous segregation along the facet
ł		1

The general boundaries are always continuously microetched (Fig. 6); on the other hand, it is necessary to point out that in Ni-OS general boundaries are never microetched, even in the most agressive thinning conditions; these general boundaries are non symmetrical but usually one of the two boundary planes is compact. In Ni-16S, general boundaries are non symmetrical too, but none of the boundary plane is ever compact.

In a facetted Σ = 3 boundary (Fig. 7), sulfur segregates strongly in symmetrical facet {110} (or more rarely {210}) but never in symmetrical facets {111} or {211}. These observations are coherent with the different excess volumes and substitutional possibilities predicted by the FCC Hard Sphere Crystals Model /16/. Punctual segregation occurs along non symmetrical facets {111}_A {311}_B, i.e. when only one grain boundary plane is compact.

From this part, a correlation has been established between the segregation level of a grain boundary and its structure. It enables the choice of interesting areas for STEM investigations.

II - 3 - SELECTION OF APPROPRIATE GRAIN BOUNDARIES FOR EXPERIMENTS OF DETECTION OF INTERGRANULAR SULFUR BY STEM. (Ni-16)S.

For obvious reasons, the foils are thinned by ion-milling. After the determination of the grain boundary structure and according to the precedent results, only the foils with general boundary and/or facetted $\Sigma = 3$ {110} or {210} are selected for STEM study.

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Fig. 6 - Continuous microetching of a general grain boundary in Ni-16S.





b)

- Fig. 7 Facetted Σ = 3 grain boundary.
 - a) the symmetrical facet {111} is not etched the symmetrical facet {110} is continuously microetched
 - b) the non symmetrical facet $\{111\}_A$ $\{311\}_B$ is ponctually microetched.
- III DIRECT EVIDENCE, WITH AN ANALYTICAL EM TECHNIQUE, OF SULFUR INTERGRANULAR SEGREGATION

As a consequence of the very localized nature of this segregation problem, one has to appeal to the high spatial resolution capability of a dedicated analytical STEM /17/. Two signals have been used : the ionization edges in an Electron Energy Loss (EELS) spectrum, the characteristic emission lines in an X-ray Emission (EDX) spectrum. When used for the study of a specimen feature such as a grain boundary with plane parallel to the incident beam, it is important to define the extension and localization of the analyzed volume. The <u>irradiated volume</u> is determined by the size and shape of the probe combined with the dimension and shape - rectangular or linear - of the scanned area, together with the beam spread along its propagation through the foil /18/. In most situations of the present work, the diameter of the beam at the entrance surface is of the order of 2 to 3 nm ; it can increase to about 10 nm at the exit surface for foils of the order of 60 nm thick. The actual generation volume of the recorded signal can be slightly different from the irradiated volume. As a matter of fact, the electrons contributing to the EELS signal are collected through the spectrometer entrance aperture so that they are contained within an instrumentally defined cone. X-ray photons in EDX originate not only from the whole irradiated volume but also from specimen areas outside of the beam due to large angle scattered primary electrons. It could therefore be thought that the optimum technique for the detection of an element segregated in a very small volume is EELS performed in conditions chosen to maximise its relative concentration in the analysed volume as checked in other circumstances /19/. In the present study, we have found that the difficulties associated in positioning the probe on the interface in a real problem, introduce limitations so that the two methods (EELS and EDX) perform a nearly equivalent level of performance, as it is illustrated by the following analysis on the same grain boundary well defined as a general grain boundary.

EELS ANALYSIS : PERFORMANCES, PROBLEMS AND RESULTS

For a pure Ni foil the main core-loss contribution in EELS are the M23 and L23 edges at 65 and 855 eV. The presence of S can be revealed by its L_{23} edge at 164 eV with a maximum at \simeq 200 eV or its K edge at 2470 eV with a maximum at 2480 eV. Using simple considerations involving the relative magnitude of signal, background and crosssections such as explained in /20/ it is possible to evaluate the minimum detectable concentrations at about 1 weight % when using the S-L23 signal and 10 weight % with the S-K signal. These estimations assume a satisfactory definition and a possible measurement of the signals after background stripping. If it does not present any serious difficulty concerning the K-edge (of however poor detection capability), it is not the case for the L_{23} edge of sulfur superposed on the decreasing tail of the Ni-M_23 edge. As shown in Fig. 8, the energy loss background due to the matrix cannot be fitted to a power-law model in the 100-200 eV domain because of the extended fine structures of the M23 edge. We have therefore developed a method of extracting the S-signal by difference of two spectra recorded in the same conditions on two adjacent areas on the boundary and close to it. Fig. 9 shows the results of the difference of the two spectra of Fig. 8 after normalization of the intensities in two channel chosen on the maximum of the M_{23} edge of nickel at 67 eV or on the background at 160 eV just before the position of the searched S- L_{23} edge at 164 eV. The problem is even made more complex because there is also a slight contamination with silicon made visible by its L23 edge at 100 eV towering at about 125-130 eV. When processing these data for quantitation, one can estimate an average concentration of $\simeq 1-1,5$ weight % in S as well as in Si in the analyzed volume. These numbers correspond to a segregation of $\simeq 1/3$ to 1/2 of a monolayer of S and Si impurities in the boundary, when taking into account the full width of the analyzed area of the order of 25 nm².





Fig. 9 - Difference between (a) and (b) EELS spectra of Fig. 8 when the intensity is normalized on the top of the Ni- M_{23} edge 67 eV (top curve) or at 160 eV just before the S-L₂₃ edge 164 eV (bottom curve) at channels shown by a larger dot. One can estimate the relative S concentration with respect to the intensity of the Ni-L₂₃ lines (not shown in this figure but recorded in the same scan) by using the following cross-sections values :

 σ_{S-L23} (25 mrad, 100 eV) = 6.6 x 10⁻²⁰ cm² σ_{Ni-L23} (25 mrad, 100 eV) = 2.6 x 10⁻²¹ cm²

EDX ANALYSIS : PERFORMANCES, PROBLEMS AND RESULTS

Though its poorer definition of the analysed volume, EDX offers a more reproducible way of analysing sulfur in grain boundaries as a consequence of its better performance in minimum concentration (nearly ten times better than for EELS). It results from the weaker background under the characteristic K lines of sulfur and silicon (Fig. 10). In both cases, on the boundary and on the matrix, the irradiated volume is at least three times bigger than in the EELS case. A qualitative comparison of spectra recorded in \simeq 400 s, clearly shows the presence of S and Si in the boundary (Fig. 11). When processed for quantitation, a typical result of segregation profile is shown in Fig. 12. These data have to be deconvoluted from probe size and beam spreading effects /21/ to offer a more quantitative estimation of sulfur segregation in the grain boundary, which seems to be roughly in agreement with the EELS results. More systematic studies on different types of boundary are now in progress with EDX because it is a simpler-to-use method for controlling the quantitation of sulfur segregation in nickel grain boundaries.



Fig. 10

Fig. 12

Fig. 10 - EDX spectrum (0 \rightarrow 10 keV) recorded on the grain boundary.

Fig. 11 - EDX spectra ($0 \rightarrow 5 \text{keV}$) recorded on the boundary and on the matrix.

Fig. 12 - Results of EDX analysis of sulphur for the analyzed volume localized respectively on the boundary and at different positions away from the boundary in both grains A and B (probe size typically 10 nm).

Fig. 11

It seems difficult to improve these limits of detection because it is impossible at the present time to reduce the analysed volume to the scale of grain boundary dimension.

DISCUSSION

The general purpose of this work, still in progress, is to establish the most accurately interconnected possible relation between grain boundary structure - quantitative measurements of intergranular sulfur segregation - electrochemical reactivity. This will be the object of the discussion.

As for the correlation electrochemical reactivity - grain boundary structure, the following points may be underlined :

- In Ni-16S material, the very large spread of electrochemical penetration values can be partly related to the results of TEM study : 81% of the boundaries exhibit a very deep groove when 83% of the boundaries are determined as general grain boundaries (Σ = 3 grain boundaries are excluded in these evaluations). This confirms the fact that electrolytic microetching of these general boundaries can be associated to maximum sulfur segregation. C4-514

- In Ni-OS material, 20% of the boundaries are general but never microetched; only 2% of all boundaries present a weak but measurable groove. This result is an evidence for the high sensitivity of electrochemical test to segregation and this low percentage can be explained by crystallographical characteristics : one reminds that usually one of the two boundary planes is compact in these high purity nickel general grain boundaries.

The correlation grain boundary structure - STEM measurements of sulfur segregation has been demonstrated since a sulfur equilibrium segregation has been finally measured in a general nickel grain boundary. Recent experiments indicate that it will be possible to evaluate quantitatively this correlation for other grain boundary structures (special and facetted $\Sigma = 3$).

This work will be pursued as follows:

- We propose to calculate from numerical values of α and D, angle and depth of electrochemical corrosion grooves, a specific parameter to grain boundary : the intergranular atomic volume $(M/\rho)_{\rm gb}$. This last one is characteristic of the atomic disorder and of the nature of the segregated element in the grain boundary. A characteristic evolution has been shown for intergranular $(M/\rho)_{\rm gb}$ versus intergranular sulfur content measured by AES in a technic nickel /2/. This calculation will allow an evaluation of sulfur content grain boundary by grain boundary and a new correlation with structural and quantitative analysis.

- By TEM the important feature of our results is that in Ni-16S the special grain boundaries are nearly all Σ = 3 while in Ni-OS they are able to adopt any coïncidence configuration of any low Σ . This result can be explained either by the presence of sulfur in solid solution in Ni-16S at 1050°C or by the phenomenon of intergranular segregation at 625°C. The determination of statistical distribution of grain boundary types in Ni-16S heat-treated at 1050°C - 4 hours should allow us to decide between these two hypotheses. Furthermore, a TEM study of the 1050°C - 4 hours,12days 625°C, Ni-16S specimen will be undergone to see if there is any precipitation, in order to explain the diminution of segregation for a heat-treatment longer than two days (Fig. 4).

- Now the X-ray analysis by STEM will be performed in order to give a quantitative concentration of the segregated sulfur monolayer. A model is being developed for the X-ray generation volume specific to very narrow beam and deconvolution of matrix and grain boundary signals.

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